

ABSTRACT**Lithographic Apparatus and Device Manufacturing Method**

An array of individually controllable elements comprised of elements, each formed of a stack of layers of dielectric material, at least one layer of which is an electro-optical material
5 such that its refractive index for radiation that is plane polarized in a given direction, can be changed by application of a voltage in order to change the reflection/transmission characteristic of the boundary between this layer and the adjacent layer.

Fig. 2